Surface characterization of Mn$_x$Ge$_{1-x}$ and Cr$_y$Mn$_x$Ge$_{1-x-y}$ dilute magnetic semiconductors

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We have used x-ray photoemission electron microscopy (XPEEM) and x-ray absorption spectroscopy (XAS) to characterize Mn$_x$Ge$_{1-x}$ and Cr$_y$Mn$_x$Ge$_{1-x-y}$ films grown by molecular beam epitaxy. The surface layers of the as-grown films probed by XPEEM present segregation of Mn-rich phases. XAS using both total electron yield and fluorescence yield detection shows that the films are heavily oxidized after exposure to air. Etching in HF and HCl can be used to reduce oxidation, but inhomogeneities in the surface composition might not be completely eliminated depending on the Mn concentration. X-ray magnetic circular dichroism (XMCD) measurements reveal that neither the etched nor the as-grown films present remanent ferromagnetic behavior down to a temperature of 5 K within the probing depth of the fluorescence yield (~20 nm). Mn is paramagnetic in both the oxidized and etched samples, with an increased tendency to order magnetically toward the interior of the films. Cr in Cr$_x$Mn$_y$Ge$_{1-x-y}$ possesses a paramagnetic moment only in the oxidized form. A comparison of the XAS line shapes obtained in the present study with those of Mn impurities deposited on Ge and GaAs surfaces demonstrates that the interpretation of XAS spectra of Mn-doped dilute magnetic semiconductors in the literature is often affected by residual oxidation.

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I. INTRODUCTION

Substitutional incorporation of transition-metal dopants into nonmagnetic semiconductors such as GaAs (Ref. 1) and Ge (Ref. 2) in nonequilibrium growth conditions leads to ferromagnetic ordering in the doped compounds with Curie temperatures up to 250 K.\textsuperscript{3} Dilute magnetic semiconductors (DMS) obtained in this way offer exciting opportunities to combine the electronic and optical properties of semiconducting materials with the storage and processing of magnetic information.\textsuperscript{4,5} Although most activity is focused on group III-Mn-V materials, there is steadily increasing interest in Ge-based DMS, driven by their potential integration in standard Si semiconductor technology.\textsuperscript{2,6–13}

Several growth techniques have been employed to produce MnGe compounds, including low-temperature molecular beam epitaxy (MBE),\textsuperscript{2,6–9} furnace melting,\textsuperscript{14,15} and implantation of high-energy Mn$^{2+}$ ions into single crystal Ge wafers.\textsuperscript{16–18} The investigation of the magnetic properties of MnGe compounds, however, reveals very significant differences depending on the growth method. Mn$_x$Ge$_{1-x}$ films with $x=2.5–5\%$ grown by MBE between 50 °C and 85 °C yield an extrapolated Curie temperature of about 115 K from a Curie-Weiss fit of the susceptibility and ferromagnetic remanence below 20 K,\textsuperscript{2,7} while films grown at 160 °C present hysteretic behavior up to 250 K,\textsuperscript{19} and Mn$_x$Ge$_{1-x}$ single crystals obtained from melted powders are antiferromagnetic below 150 K and ferromagnetic from 150 to 285 K.\textsuperscript{14,15} These apparently conflicting observations can be rationalized in terms of coexisting chemically inhomogeneous Mn phases,\textsuperscript{7,8,15,16,18} and by the variety of Mn-rich precipitates that exhibit ferromagnetism up to room temperature, such as Mn$_3$Ge$_2$ (Ref. 20) and Mn$_3$Ge$_3$\textsuperscript{21} According to transmission electron microscopy cross-sectional analysis and x-ray diffraction data, the formation of MnGe precipitates is inhibited only in epitaxial thin films grown below 85 °C.\textsuperscript{2,7} Such substitutional Mn$_x$Ge$_{1-x}$ DMS present hysteretic behavior at low temperature ($T$<20 K), and evidence of short-range ferromagnetic order up to about 115 K,\textsuperscript{2,7} which has been attributed to the formation of bound magnetic polarons.\textsuperscript{7,22} Gated extraordinary Hall effect measurements have proven that ferromagnetic order in these systems is enhanced or suppressed depending on hole injection or depletion, respectively, as expected for Mn-doped DMS.\textsuperscript{2}
The aim of the present study is to characterize the surface composition and magnetic behavior of Mn$_x$Ge$_{1-x}$ and Cr$_x$Mn$_y$Ge$_{1-y-x}$ DMS films grown by low temperature MBE, which we show to differ from the bulk owing to segregation of the dopants, surface contamination, and interface effects. The interest in this type of investigation is twofold. On the one hand, it is important to establish the interface properties of DMS due to the dependence of spin transport on the nature and quality of DMS surfaces\textsuperscript{23} and their anticipated integration in layered semiconductor heterostructure devices as magnetic elements and spin polarizers.\textsuperscript{4,5} On the other hand, as x-ray absorption spectroscopy (XAS) is one of the main tools employed to study the dilution and valence configuration of Mn in DMS,\textsuperscript{15,17,24–30} we wish to emphasize the need of XAS data representative of pure and homogeneous DMS, i.e., with a minimal amount of surface contaminants and phase segregation. By comparing XAS spectra recorded using total electron yield (TEY) detection with fluorescence yield (FY) spectra and the TEY spectra of Mn impurities deposited on Ge and GaAs surfaces, we show that the ground state of substitutional Mn in Ge, as also in GaAs,\textsuperscript{29,30} has a hybridized character. Well-defined multiplets in the $L_{2,3}$ XAS spectra of Mn, indicative of a localized $d^3$ ground state and observed both in Mn$_x$Ge$_{1-x}$ (Refs. 15 and 17) and Ga$_{1-x}$Mn$_x$As,\textsuperscript{24–26,28} originate from oxidation of the Mn atoms in the surface layers within the XAS probing range.

II. EXPERIMENTAL TECHNIQUES

Mn$_x$Ge$_{1-x}$ and Cr$_x$Mn$_y$Ge$_{1-y-x}$ films with typical thickness of 1000 Å were grown by MBE on GaAs(001) substrates at $T=70$ °C and left uncapped. Their bulk structural and magnetic properties are described in Refs. 2 and 6. In the present study we investigated films with composition Mn$_{0.025}$Ge$_{0.975}$, Mn$_{0.025}$Ge$_{0.92}$, Mn$_{0.025}$Ge$_{0.975}$, and Cr$_{0.022}$Mn$_{0.025}$Ge$_{0.953}$, the last two corresponding to samples Nos. 515A and 516 in Ref. 6. The Mn concentrations were determined by small-spot transmission electron microscopy analysis of the interior of the film.\textsuperscript{2} The magnetization measured by superconducting quantum interference device (SQUID) prior to the XAS measurements as a function of temperature and applied field was consistent with previously reported data,\textsuperscript{2,6} displaying remanent ferromagnetism at 5 K, as shown in Fig. 1.

X-ray photoemission electron microscopy (XPEEM) was performed at the SIM beamline of the Swiss Light Source. XPEEM images were recorded at room temperature as a function of photon energy over the $L_{2,3}$ edges of Mn, Cr, and Ge, and the $K$ edge of O with a field of view of 50 μm. Elemental contrast was obtained by dividing pixel-by-pixel the intensity of two consecutive images recorded at pre-edge and on-edge energies for each element. Images recorded with left or right circular polarization showed no detectable difference due to the room temperature magnetic response of the samples. XAS and x-ray magnetic circular dichroism (XMCD) spectra were measured as a function of $T$ and applied field $B$ at beamline ID08 of the European Synchrotron Radiation Facility using simultaneous TEY and FY detection. The TEY signal was given by the sample drain current measured by an electrometer, while the FY was measured by means of a Si photodiode detector. The angle of incidence of the x-ray beam was set to $\theta=45^\circ$ with respect to the surface normal and the XMCD was recorded by reversing the alignment of the photon helicity relative to B. Films from the same wafer were measured as-grown and after etching in dilute solutions (1:10) of HF:H$_2$O and HCl:H$_2$O for 30 s each. Here HF was used to selectively etch Ge oxide, while HCl served to remove segregated Mn and Mn oxide, as will be shown below. The etched samples were rinsed in deionized H$_2$O and exposed to air for up to 10 minutes before introduction into the ultrahigh-vacuum environment.

III. RESULTS AND DISCUSSION

A. X-ray photoemission electron microscopy

Figure 2 shows a series of XPEEM images of the as-grown Cr$_{0.022}$Mn$_{0.025}$Ge$_{0.953}$ sample with Mn, Cr, O, and Ge contrast. Bright and dark regions correspond to relative high or low concentration of the respective elements in the topmost surface layers. As for XAS in the TEY mode, the probing depth of XPEEM is given by the mean free path of the secondary photoelectrons that escape the sample’s surface (typically in the range of 2 nm, although variations are observed from element to element). The XAS spectra to the left of the images represent the average intensity of the photoelectrons emitted from the rectangular (solid line) and circular (dashed line) regions indicated on the top image. The analysis of the images reveals at first glance that the film surface is not homogeneous owing to the segregation of Mn-rich phases with poor Cr and Ge content. A close inspection of the images recorded at the O $K$ edge shows that O is more abundant in such phases. These observations are confirmed by the difference in the relative intensity of the XAS spectra measured in correspondence of the Mn-rich regions (dashed lines) with respect to the homogeneous parts of the surface (solid lines). The elemental spectra are normalized to the pre-edge intensity for ease of comparison.

No Cr-rich phases have been observed within the XPEEM resolution. The intense O XAS peaks further reveal that the whole film surface is heavily oxidized. In fact, the sharp multiplet structures observed in the Mn and Cr XAS in Fig.
are due to electron localization and are typical of MnO (Refs. 31 and 32) and CrO₂ (Refs. 33 and 34) compounds. The Mn d-state in the oxide compound, in particular, is very close to the atomic d⁵ ground state by virtue of the stability of the 6S term of a half-filled d-shell (see Sec. III B).³⁵,³⁶

Apart from the absence of Cr, XPEEM images of the as-grown MnₓGe₁₋ₓ films reveal analogous features to those described above, namely the presence of Mn- and O-rich phases with μm size dimensions and significant oxidation of the film surface.

After etching in HF and HCl, the CrₓMnᵧGe₁₋ₓᵧ and MnₓGe₁₋ₓ samples present a more chemically homogeneous surface, and oxidation is considerably reduced. Figure 3 shows XPEEM contrast and XAS spectra representative of the homogeneous surface of etched Mn₀.₀₁₈Ge₀.₉₈₂. The Mn line shape presents no discernible multiplet structure in this case, in agreement with the low O contamination evidenced by the O XAS. On Mn₀.₀₂₅Ge₀.₉₇₅ and Cr₀.₀₂₂Mn₀.₀₂₅Ge₀.₉₅₃, however, by scanning the sample surface over mm regions with a 50 μm field of view, we occasionally observe residual inhomogeneities that are not present on Mn₀.₀₁₈Ge₀.₉₈₂, possibly due to the larger concentration of dopants and increased segregation in the former compounds. One such case is shown in Fig. 4. The gray contrast area is typical of etched Cr₀.₀₂₂Mn₀.₀₂₅Ge₀.₉₅₃ with uniform Mn, Cr, and Ge composition, and reduced oxidation solid line XAS spectra. Two Mn-rich inclusions are shown, which appear to be composed of MnO with negligible Cr and Ge content dashed line XAS spectra. We note that the Mn line shape corresponding to the oxidized region is practically identical to that of the as-grown samples (Fig. 2), while the multiplet features are broadened and hardly distinguishable in the spectra corresponding to the uniform region. As the TEY peak-to-background ratio of the L₂,₃ Mn edge decreases by 75% in etched Cr₀.₀₂₂Mn₀.₀₂₅Ge₀.₉₅₃, while the FY intensity stays almost constant (not shown), there is evidence that acid exposure reduces the surface concentration of Mn relative to the interior of the film.

B. Total electron yield and fluorescence yield x-ray absorption spectroscopy

Further insight into the valence state of Mn in Ge-based DMS comes from the comparison of XAS spectra recorded in the TEY and FY mode. In this section, the XAS is integrated over a 0.₁₁ × 1 mm² region with no spatial resolution. Due to the larger escape depth of photons with respect to electrons, FY spectra contain information about deeper layers compared to TEY and XPEEM typically up to 20 nm
from the sample surface for FY compared to 2 nm for TEY (Refs. 37 and 38). Figure 5 shows the TEY (a) and FY (b) spectra of as-grown Mn$_{0.025}$Ge$_{0.975}$ and etched Mn$_{0.018}$Ge$_{0.982}$. The spectra represent the sum of the XAS intensity recorded with left ($I_L$) and right ($I_R$) circular polarization. We note that no distinction exists between $I_L$ and $I_R$ in the absence of applied field or magnetic remanence. The TEY data of the as-grown sample reproduce the multiplet features observed in Fig. 2 and in the oxidized regions of Fig. 4. These features are present also in the FY spectrum, showing that Mn oxidation reaches layers 10–20 nm deep in as-grown Mn$_x$Ge$_{1-x}$ exposed to ambient conditions. As expected from the analysis of the preceding section, the multiplet peaks in the TEY of etched Mn$_{0.018}$Ge$_{0.982}$ are broadened due to the reduced oxidation of the surface layers. However, contrary to the sample studied by XPEEM (Fig. 3), oxidation in this sample is not entirely removed. A possible cause is the additional time (oxidation) intervened between XPEEM and XMCD studies, even though the sample’s wafer and the etching protocol were the same in both cases. In the following we will refer to this case as “partially etched.” The absence of multiplet features in the corresponding FY spectra shows that the inner layers are oxygen free and that the Mn line shape representative of Mn$_x$Ge$_{1-x}$ DMS derives from a ground state with a substantial degree of electron delocalization.

In Fig. 5(a) we report for comparison the Mn $L_{2,3}$ XAS calculated for the atomic $d^5$ ground state in the absence of crystal field taking into account the $2p$-$3d$ and $3d$-$3d$ Coulomb and exchange interactions, as well as the $2p$ and $3d$ spin-orbit interactions, as described in Ref. 36. As mentioned above, such a spectrum is typical of the localized Mn$^{2+}$ valence state observed in MnO. 31,32,35,36 The agreement with
the XAS measured on the as-grown samples is excellent, showing that the multiplet spectra are due to oxidation rather than being representative of substitutional Mn in Ge. Indeed, as revealed by the spectra reported in Figs. 3 and 5(b), the line shape of substitutional Mn is more similar to that observed for metal systems than to that belonging to a localized configuration with dominant $d^5$ character. This is attributed to substantial hybridization between the Mn 3$d$-states with Ge 4$p$-states, as shown also by first-principles theoretical calculations. To lend further support to the line shape assignment we consider the Mn $L_{2,3}$ XAS measured on individual Mn impurities deposited at low temperature (5 K) on Ge(111) single crystal surfaces. The reduced coordination of surface impurities generally favors electron localization, resulting in richly structured XAS spectra. However, the impurity spectra of Mn on Ge(111) present broad and relatively featureless peaks compared to the as-grown Mn$_x$Ge$_{1-x}$ films. Intentional oxidation of the surface impurities, on the other hand, leads to the typical $d^0$ oxide spectrum.

These conclusions can be generalized to the XAS analysis of Mn$_x$Ge$_{1-x}$ compounds reported in the literature, which are evidently affected by oxidation. Analogous deductions were reached for Ga$_{1-x}$MnAs compounds. In a recent study, Wu et al. compared TEY and FY XAS spectra of as-grown Ga$_{1-x}$MnAs, observing that the TEY multiplet structure is absent in FY. Edmonds et al. showed that the surface of Ga$_{1-x}$MnAs films grown by MBE is rich in Mn and O, which can be removed by etching in HCl. The XAS spectra of the etched compounds are similar to those presented here for Mn impurities deposited on GaAs(110) and have been interpreted in terms of a mixed Mn ground state with 16% $d^4$, 58% $d^6$, and 26% $d^8$ character. It is interesting to note that the XMCD, i.e., the magnetic moment per Mn atom, results to be much larger in Ga$_{1-x}$MnAs free of MnO (Refs. 27, 29, and 30) compared to Ga$_{1-x}$MnAs where the XAS indicates partial oxidation.

Finally, we remark that Mn$_x$Ge$_{1-x}$ films present a broader FY linewidth [Fig. 5(b)] compared to Ga$_{1-x}$MnAs, where the full width at half-maximum of the Mn $L_3$ peak is about 2 eV. This difference might be due to the fact that our FY intensity is not corrected for self-absorption effects, leading to an effective reduction of the peak signal. However, it might also indicate stronger hybridization of Mn with Ge relative to GaAs, as well as the presence of multiple Mn site locations within the Ge lattice.

C. X-ray magnetic circular dichroism

The magnetic behavior of as-grown and etched Mn$_x$Ge$_{1-x}$ and Cr$_x$Mn$_{1-x}$As$_x$ was studied by XMCD at the $L_{2,3}$ Mn and Cr edges. None of the investigated films displayed a remanent XMCD signal in the temperature range 300–5 K, although Mn atoms possess a paramagnetic moment in all samples. We discuss here the data obtained on partially etched Mn$_{0.018}$Ge$_{0.982}$ to highlight the different magnetization characteristics measured by TEY and FY. Figure 6 shows the XAS recorded for parallel ($I_R$, dashed line) and antiparallel ($I_L$, solid line) alignment of the photon helicity with $B = 5$ T at $T = 5$ K in the TEY (a) and FY (c) mode. The XMCD

![FIG. 6. (Color online) (a) TEY x-ray absorption spectra of partially etched Mn$_{0.018}$Ge$_{0.982}$ recorded for parallel ($I_R$, dashed line) and antiparallel ($I_L$, solid line) alignment of the photon helicity with applied field $B = 5$ T at $T = 5$ K. Mn $L_{2,3}$ absorption edge. (b) TEY XMCD ($I_R-I_L$) as a function of $B$ at $T = 5$ K. The inset shows the Mn magnetization measured by the intensity of the $L_1$ peak vs B. XMCD units are given relative to the (arbitrary) XAS intensity. (c) and (d) recorded simultaneously with (a) and (b) in FY.](125211-5)
absence of magnetic remanence is evident from the flat XMCD observed at $B=0$. This result is not unexpected for the TEY signal, which is representative of the MnO-rich surface phase, as MnO is known to be antiferromagnetic with a Néel temperature of 120 K. The zero remanence in the FY XMCD, however, is surprising given the bulk hysteretic magnetization reported in Fig. 1 and in Refs. 2 and 6. A conceivable explanation for this effect lies in the dependence of ferromagnetic order on the hole density in $\text{Mn}_x\text{Ge}_{1-x-y}$, which might be reduced in proximity of the film surface due to hole depletion. Alternatively, if coalescence of magnetic polarons is considered the mechanism responsible for the onset of hysteretic behavior in $\text{Mn}_x\text{Ge}_{1-x}$, below 20 K, it is possible that missing “links” between polarons on the surface side effectively reduce their magnetic coupling, resulting in a decrease of the temperature at which magnetic ordering occurs. In agreement with both explanations, the comparison between TEY and FY data reveals a tendency to ferromagnetic coupling that increases towards the film interior. The Mn magnetization recorded as a function of $B$ [insets of Figs. 6(b) and 6(d)] is steeper for FY compared to TEY, indicating that the Mn susceptibility is larger in the inner layers of the film relative to the surface. Moreover, the FY curve saturates at lower field compared to individual high-spin Mn impurities. A Brillouin fit of the magnetization with Landé factor $g=2$ gives an effective moment of $5.2\pm0.2\mu_B$ for the TEY curve and $64\pm6\mu_B$ for the FY curve, which, in the latter case, indicates the presence of short-range ferromagnetic coupling among Mn dopants.

Finally, we consider the XMCD of $\text{Cr}_{0.022}\text{Mn}_{0.025}\text{Ge}_{0.953}$, shown separately for Mn and Cr in Figs. 7(a) and 7(b). The addition of Cr was investigated in order to increase the hole density and enhance the magnetization characteristics of $\text{Mn}_x\text{Ge}_{1-x-y}$, but was shown to systematically reduce the Curie temperature and saturation magnetization of the mixed compounds. In light of these observations, it is interesting to know whether Cr has a magnetic moment antiferromagnetically coupled to Mn or no net magnetization. Here we show that Cr possesses a paramagnetic moment only when oxidized [TEY data in Fig. 7(b)], in which case the sign of the XMCD indicates that it is aligned parallel to the Mn moment. In the FY Cr data, on the other hand, no clear XMCD signal emerges from the noise. Thus Cr in the interior of the film has no net magnetization, consistently with either a non-magnetic ground state or strong antiferromagnetic coupling between neighboring Cr impurities. The observed reduction of the saturation magnetization observed in Cr$_x$Mn$_y$Ge$_{1-x-y}$ in spite of the increased hole density can tentatively be explained by the formation of MnCr clusters with reduced or no magnetic moment.

IV. CONCLUSIONS

In summary, we have shown that the surface composition of $\text{Mn}_x\text{Ge}_{1-x}$ and Cr$_x$Mn$_y$Ge$_{1-x-y}$ films grown by molecular beam epitaxy is not homogeneous due to segregation of Mn-rich phases. The as-grown films present severe oxidation reaching 10–20 nm deep into the films, which can be removed by etching in HF and HCl dilute solutions. Contrary to MnO, the Mn XAS line shape representative of oxidation-free $\text{Mn}_x\text{Ge}_{1-x}$ has no pronounced multiplet features and reveals delocalization of the Mn $d$-states due to hybridization with Ge. We did not observe ferromagnetic remanence either by TEY or FY in as-grown or etched samples between 300 and 5 K, implying that the film surface layers have different magnetic properties with respect to the bulk. FY measurements in partially etched Mn$_x$Ge$_{1-x}$ show indications of ferromagnetic coupling between Mn dopants relative to the oxidized topmost layers probed by TEY. Cr in Cr$_x$Mn$_y$Ge$_{1-x-y}$ has no net magnetization unless it is oxidized, in which case it behaves paramagnetically. These results prove that DMS surface properties such as segregation and contamination, as well as differences in the volume vs interface characteristics of semiconductors might significantly affect their magnetic behavior.

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The thickness $t$ of the surface depletion layer can be estimated by $t \sim \frac{\pi \varphi_0}{eN} \sim 10 \text{ nm}$, where $\varphi_0 = 0.5 \text{ V}$ represents the band bending and $N = 10^{19} \text{ cm}^{-3}$ the carrier density.